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PATENT
Docket No. 150.00560102

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Lee et al.) Group Art Unit: 1765
)
Serial No.: 09/560,268) Examiner: D. Deo
Confirmation No.: 2517)
)
Filed: 26 April 2000)
)
For: COMPOSITIONS FOR SELECTIVELY ETCHING AGAINST COBALT
SILICIDE (As Amended)

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AMENDMENT AND RESPONSE

Assistant Commissioner for Patents
Washington D.C. 20231

Dear Sir:

In response to the Office Action dated 3 July 2002, please amend the above-identified application as follows:

In the Claims

Please amend claims 64 and 94, and cancel claims 66 and 96. The amended claims are provided below in clean form. Per 37 C.F.R. § 1.121, amended claims are also shown in Appendix A with notations to indicate changes made (for convenience, all pending claims are provided in Appendix A).

~~64. (Once Amended) An etching composition, the composition comprising a mineral acid, a peroxide, and deionized water at a ratio in a range of about 1:1:25 (mineral acid:peroxide:deionized water) to about 1:1:10 (mineral acid:peroxide:deionized water).~~

~~94. (Once Amended) An etching composition, the composition comprising a mineral acid, a peroxide, and deionized water at a ratio in a range of about 1:1:25 (mineral acid:peroxide:deionized water) to about 1:1:10 (mineral acid:peroxide:deionized water), wherein~~